

## CLAIMS

1. A non-thermal plasma reactor characterized by:  
 an element prepared from an extruded curved substrate  
 comprising an outer wall surrounding a plurality of concentric channels  
 separated by dielectric barriers, said element comprising:

- 5 a plurality of exhaust channels for passing a flow of gas  
 therethrough; and  
 a plurality of conductor channels, said conductor channels  
 having alternating polarity, each connected to its respective polarity via bus  
 paths.

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2. The reactor of claim 1, wherein said curved substrate  
 comprises a dielectric substrate material selected from the group consisting of  
 alumina, dense cordierite, mullite, titania, plastic, materials having a high  
 dielectric constant, and combinations thereof.

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3. The reactor of claim 1, wherein said exhaust channels  
 are thick relative to said conductor channels.

4. The reactor of claim 1, further comprising:  
 a catalytic coating disposed on interior walls of said exhaust  
 channels.

5. The reactor of claim 1, wherein said conductor channels  
 are coated with conductive media selected from the group consisting of silver  
 inks, aluminum ink, and copper inks, and combinations thereof.

6. The reactor of claim 1, further comprising:  
structural support ligaments, wherein said ligaments comprise  
an integrally extruded portion of said curved substrate.

7. The reactor of claim 6, wherein at least one structural  
support ligament serves as a substrate for said conductive bus paths.

8. The reactor of claim 6, wherein portions of said  
structural support ligaments are removed from said conductor channels in  
order to ensure continuous conductive paths along said conductor channels.

9. The reactor of claim 6, wherein face ends of said  
structural support ligaments disposed in said conductor channels have a  
conductive coating disposed thereon.

10. The reactor of claim 6, wherein said structural support  
ligaments are lined up between said conductor channels and said exhaust  
channels so that there are essentially no uncoated areas in said conductor  
channels.

11. The reactor of claim 1, further comprising:  
an electrical insulating sealant.

12. The reactor of claim 1, wherein said curved substrate  
comprises a shape selected from the group consisting of curved, swept, round,  
oval, racetrack, and trapezoid shapes.

13. The reactor of claim 1, wherein said curved substrate comprises a shape comprising a large frontal area and a length that is short relative to said frontal area.

14. The reactor of claim 1, wherein said curved substrate comprise a shape having a frontal area that is sufficiently large to achieve a low backpressure and a length adjusted to achieve a desired gas space velocity in accordance with a particular engine emission system.

15. The reactor of claim 1, comprising wire connections made directly to said bus paths.